

Title (en)

GOLD ELECTROPLATING SOLUTION AND ITS USE FOR ELECTRODEPOSITING GOLD WITH AN AGED APPEARANCE

Title (de)

GOLDGALVANISIERUNGSLÖSUNG UND IHRE VERWENDUNG ZUR GALVANISCHEN ABSCHEIDUNG VON GOLD MIT GEALTERTEM AUSSEHEN

Title (fr)

SOLUTION D'ÉLECTRODÉPOSITION DE L'OR ET SON UTILISATION POUR L'ÉLECTRODÉPOSITION DE L'OR AVEC UN ASPECT VIEILLI

Publication

EP 4245893 A1 20230920 (EN)

Application

EP 22305294 A 20220315

Priority

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Abstract (en)

The invention relates to a gold electroplating solution comprising gold in the form of a complex with a compound of formula (I) or a salt thereof: $R^{¹}S-Ar-CO₂H$ (I) Wherein : $R^{¹}$ is H, a C₁-C₆ alkyl group or -S-Ar-CO₂H, Ar is, at each occurrence, independently, selected from a C₆-C₁₀ arylene or a 5 to 10 membered heteroarylene group, notably a phenylene, a pyridinylene, a furanylene, a pyrrolylene, or a thienylene group.

IPC 8 full level

C25D 3/48 (2006.01); **C25D 3/62** (2006.01)

CPC (source: EP)

C25D 3/48 (2013.01); **C25D 3/62** (2013.01)

Citation (applicant)

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Designated contracting state (EPC)

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